

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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<b>Title of Invention</b>	RAISED STI PROCESS FOR MULTIPLE GATE OX AND SIDEWALL PROTECTION ON STRAINED Si/SGOI STRUCTURE WITH ELEVATED SOURCE/DRAIN
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Application Number :

Confirmation Number:

First Named Applicant: Jochen Beintner

Attorney Docket Number: FIS920040005

Art Unit:

Examiner:

Search string: ( 4881105 or 5801081 or 5858825 or 5874328 or 6184105 or 6197657 or 6248643 or 6333242 or 6350662 or 6358801 or 6583000 or 20010036709 or 20020094649 or 20030119257 or 20030141548 ).pn

## US Patent Documents

**Note: Applicant is not required to submit a paper copy of cited US Patent Documents**

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	4881105	1989-11-14	Davari et al.			
	2	5801081	1998-09-01	Warashina et al.			
	3	5858825	1999-01-12	Alsmeier et al.			
	4	5874328	1999-02-23	Liu et al.			
	5	6184105	2001-02-06	Liu et al.			
	6	6197657	2001-03-06	Tsukamoto			
	7	6248643	2001-06-19	Hsieh et al.			
	8	6333242	2001-12-25	Hwang et al.			
	9	6350662	2002-02-26	Thei et al.			
	10	6358801	2002-03-19	Fazan et al.			
	11	6583000	2003-06-24	Hsu et al.			

## US Published Applications

**Note: Applicant is not required to submit a paper copy of cited US Published Applications**

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
	1	20010036709	2001-11-01	Andrews et al.			
	2	20020094649	2002-07-18	Arthanari et al.			
	3	20030119257	2003-06-26	Dong et al.			

	4	20030141548	2003-07-31	Anderson et al.			
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**Signature**

Examiner Name	Date